Special Issue

Control and Optimization of Wastewater Treatment Technology

Message from the Guest Editor

This Special Issue on "Control and Optimization of Wastewater Treatment Technology" aims to curate novel advances in the development of new treatment processes along with the application of conventional treatment processes to address longstanding challenges in emerging contaminant control before it discharges to open waterways. Topics include, but are not limited to, the following:

- Development of a new technology to control chemicals of emerging contaminants;
- Resource recovery from wastewater;
- Recycling materials (e.g., slag, biochar, tire rubber) for water treatment; and
- Water quality monitoring and management.

Guest Editor

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Deadline for manuscript submissions

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Message from the Editor-in-Chief

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Editor-in-Chief

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